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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
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09/761,240

01/17/2001

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GR 98 P 2124 P

5138

27346 7590 08/21/2008  
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EXAMINER

MONDT, JOHANNES P

ART UNIT

PAPER NUMBER

3663

MAIL DATE

DELIVERY MODE

08/21/2008

PAPER

**Please find below and/or attached an Office communication concerning this application or proceeding.**

The time period for reply, if any, is set in the attached communication.



## DETAILED ACTION

### ***Response to Response filed 5/19/08***

1. Response filed 5/19/08 forms the basis for this Office Action. Comments on Remarks submitted with said Response are included below under "Response to Arguments".

### ***Claim Rejections - 35 USC § 103***

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

1. ***Claims 9 and 10*** are rejected under 35 U.S.C. 103(a) as being unpatentable over Schulze (5,610,415) in view of Rosling et al (IEEE Transactions on Power Electronics, Vol. 9, No. 5, September 1994, pages 514-521).

*Schulze teaches* a power semiconductor element, namely a GTO thyristor (title, abstract and col. 1, l. 5-32) comprising:

an emitter region 4 (either n-doped or p-doped; see col. 1, l. 47-col. 2, l. 37); and  
a stop zone 9 (col. 2, l. 3-43) in front of said emitter region (namely in region 9; see Figure),

said stop zone and emitter region having opposite conductivities (having foreign atoms, and, in the case of n-doped emitter 4 said stop zone having atoms of p-type conductivity, such as for instance gold (Au), cadmium (Cd), zinc (Zn), or nickel (Ni); in the case of p-doped emitter 4 having foreign atoms of n-type conductivity such as

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barium (Ba), molybdenum (Mo), niobium (Nb), or cesium (Cs) (see col. 2, l. 11-20).

Hence, said emitter region and said stop zone have mutually opposite conductivities, namely n- type and p-type, or p-type and n-type, respectively.

*Schulze does not explicitly teach* the limitation that said foreign atoms are either sulfur atoms or selenium atoms, on account of which they have at least one energy level within the band gap of the semiconductor and at least 200 meV away from both valence and conduction band of said semiconductor, being silent on the material embodiment of the semiconductor in explicit terms. However, it would have been obvious to include said limitation because it would have been obvious to select silicon for said semiconductor, because thyristors are in their most common embodiment made of a silicon semiconductor layer, as witnessed for instance by Rosling et al: e.g., see Abstract, second paragraph, and "I. Introduction", page 514, second column, second paragraph). With the standard selection of silicon as the thyristor's semiconductor material the above foreign atoms meet the limitation "with at least one energy level within the 'and gap of the semiconductor (i.e., silicon) and at least 200 meV away from both a conduction band and valence band of the semiconductor (silicon). *Motivation* to select silicon for the semiconductor embodiment following Rosling et al derives at least from the well-tested and cheaply manufactured device thus configured and is strongly suggested by Rosling et al themselves (see page 514, first column, "Introduction", first five (5) lines. Furthermore, although neither Schulze nor Rosling necessarily teach the specific selection of either sulfur or selenium for said atoms Applicant is reminded that it has been held that mere selection of known materials generally understood to be

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suitable to make a device, the selection of the particular material being on the basis of suitability for the intended use, would be entirely obvious. In re Leshin 125 USPQ 416. *Combination of the teaching by Rosling et al with the invention by Schulze immediately satisfies said limitation* because gold (as acceptor (A): 290 meV), barium (as donor (D): 320 meV), cesium (as donor (D): 300 meV), molybdenum (300 meV), nickel (as acceptor (A) 350 meV) have at least one energy level within the band gap of silicon and 200 meV away from both the conduction band and valence band of silicon, as witnessed by the collected and evaluated data in Sze as made of record 5/15/02, page 21, Figure 13. Because said additional foreign atoms in stop zone 9 of conductivity type opposite to that of the emitter region 4 the concentration of dopants within said stop zone 9 is elevated in comparison with the remainder of the adjoining base region 1, and hence the essential characteristics of the doping profile as claimed are met (see applicants' specification, page 6).

In the combined invention the limitation "said stop zone is only partially electrically active in the on-state and fully electrically active in the off-state for carriers emitted by the emitter region" is satisfied by admission by Applicant, because Applicant admits that said performance is achieved because of "the creation of energy levels by the doping atoms, within the band gap of the semiconductor material, lie far away from the energy levels of the conductance band and the valence band" (see [0011] in the published application or page 3 of the Specification as originally filed).

Also, in reference to the claim language referring to the aforementioned limitation, intended use and other types of functional language must result in a structural

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difference between the claimed invention and the prior art in order to patentably distinguish the claimed invention from the prior art. If the prior art structure is capable of performing the intended use, then it meets the claim.

### ***Response to Arguments***

2. Applicant's arguments filed 5/19/08 have been fully considered but they are not persuasive.

a. On applicants' comments on page 2 of Remarks on the foreign priority document: examiner finds no evidence of filing in the related case 09/761,241, the electronic file of which does not contain any foreign priority document. Nor is there any foreign priority acknowledged in the patent issued.

b. Applicants' traverse of the rejection under 35 USC 103(a) (pages 3-19) appears entirely based on an alleged failure of the prior art to recognize the suitability of a known material for an intended purpose, applying MPEP 2144.07 to the selection of the selenium and sulfur atoms for the positioning of their energy levels as claimed. However, such selection is not needed in order to arrive at a conclusion of obviousness of the claimed invention over the prior art. As stated in the previous office action, the mere selection of the most standard material embodiment of the semiconductor layer in the GTO Thyristor by Schulze results in its dopants being exactly so positioned, and hence other known dopants such as sulfur and selenium in no way distinguish over the dopants employed by the prior art as cited (that they are known is evident from Sze as made of record; Figure 13, see levels for S and Se in the case of Si). With regard

to MPEP 2144.07 the principal question is thus whether silicon is suitable as semiconductor layer material for GTO thyristor, given that sulfur and selenium are indeed known in the semiconductor technology as dopants. This question is resolved by reference to Rosling et al, available among numerous references showing the predominance of Si as the semiconductor layer material of preference for GTO Thyristors. In light of the above considerations, the arguments by Applicants fail to persuade; accordingly the rejections provided in the previous office action must stand.

### ***Conclusion***

3. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to JOHANNES P. MONDT whose telephone number is (571)272-1919. The examiner can normally be reached on 8:00 - 18:00.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Jack W. Keith can be reached on 571-272-6878. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Johannes P Mondt/  
Primary Examiner, Art Unit 3663